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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/624,929	07/23/2003	Takanori Maeda	041514-5102-01	6766
9629	7590 03/24/2005		EXAMINER	
MORGAN LEWIS & BOCKIUS LLP			DINH, JACK	
	YLVANIA AVENUE NW DN, DC 20004		ART UNIT	PAPER NUMBER
			2873	
			DATE MAILED: 03/24/2009	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/624,929	MAEDA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Jack Dinh	2873				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	ely filed will be considered timely. the mailing date of this communication. (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 23 July 2003.						
2a) ☐ This action is FINAL . 2b) ☒ This						
Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims		·				
4) ⊠ Claim(s) 1-16 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-16 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/or	vn from consideration.					
Application Papers						
9) The specification is objected to by the Examiner.						
10) \boxtimes The drawing(s) filed on <u>23 July 2003</u> is/are: a) \boxtimes accepted or b) \square objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list 	s have been received. s have been received in Application ity documents have been receive u (PCT Rule 17.2(a)).	on No. <u>09/739,646</u> . Id in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date						
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>0703</u>. 		atent Application (PTO-152)				

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DETAILED ACTION

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Claim Rejections - 35 USC § 101

A rejection based on double patenting of the "same invention" type finds its support in the language of 35 U.S.C. 101 which states that "whoever invents or discovers any new and useful process, machine, manufacture, or composition of matter, or any new and useful improvement thereof, may obtain a patent therefor, subject to the conditions and requirements of this title". Thus, the term "same invention," in this context, means an invention drawn to identical subject matter. See *Miller v. Eagle Mfg. Co.*, 151 U.S. 186 (1894); *In re Ockert*, 245 F.2d 467, 114 USPQ 330 (CCPA 1957); and *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970).

1. Claims 9-16 of the instant application are rejected under 35 U.S.C. 101 as claiming the same inventions as claims 1-8, respectively, of prior U.S. Patent No. 6,628,599 (e.g. '599). Claims 9-16 are rejected as being taken verbatim from claims 1-8 (respectively) of '599. This is a statutory double patenting rejection.

A statutory type (35 U.S.C. 101) double patenting rejection can be overcome only by canceling or amending the conflicting claims so they are no longer coextensive in scope. The filing of a terminal disclaimer <u>cannot</u> overcome a double patenting rejection based upon 35 U.S.C. 101.

Claim Rejections - 35 USC § 103

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The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all

obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the

manner in which the invention was made.

2. Claims 1-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kowarz et al.

(US Patent 6,335,831) in view of Wang et al. (US Patent 6,211,993).

Regarding claim 1, 3 and 4, Kowarz (figure 10, not drawn to scale) is interpreted as disclosing a variable optical element comprising a reference medium 58, a first area 55b and a second area 64b being formed on the top surface of the reference medium, wherein optical changes are imparted on the wavefront of light made incident onto the first and the second areas to reflect the light based on changes in optical characteristics of the first and the second areas caused by electrostatic force, wherein diffraction efficiency is changed for the light made incident on the first and the second areas based on phase changes in the first and second areas (col. 8, lines 17-54). Kowarz is interpreted as disclosing all the claimed limitations except for a piezo-electric medium layer on the first area. However, Kowarz further discloses that it is clear that a person skilled in the art can imagine other ways for actuating the variable optical element, for example, thermal actuation, piezoelectric actuation or any combination (col 6, lines 62-67). Within the same field of endeavor, Wang (figure 1) is interpreted as disclosing the teaching of a piezoelectric medium layer 104 that changes in the thickness as a result of a piezoelectric effect corresponding to voltages externally applied (col. 5, lines 12-21). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to provide a piezo-

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electric medium layer on the first area, for the purpose of increasing the thickness of the first area so the heights of the first and second area are equal (see figure 9) to create diffraction patterns.

Regarding claim 2, Kowarz (figure 10) is interpreted as further disclosing a plurality of pairs of the first and the second areas are formed one after another in a cyclic manner.

Regarding claim 4, 7 and 8, Kowarz (figure 10, not drawn to scale) is interpreted as disclosing a variable optical element comprising a first area 55b and a second area 64b that are different in thickness (height 55b and 64b), wherein optical changes are imparted on the wavefront of light made incident onto the first and the second areas to reflect the light based on changes in optical characteristics of the first and the second areas caused by electrostatic force, wherein diffraction efficiency is changed for the light made incident on the first and the second areas based on phase changes in the first and second areas (col. 8, lines 17-54). Kowarz is interpreted as disclosing all the claimed limitations except for a piezo-electric medium layer on the first area. However, Kowarz further discloses that it is clear that a person skilled in the art can imagine other ways for actuating the variable optical element, for example, thermal actuation, piezoelectric actuation or any combination (col 6, lines 62-67). Within the same field of endeavor, Wang (figure 1) is interpreted as disclosing the teaching of a piezoelectric medium layer 104 that changes in the thickness as a result of a piezoelectric effect corresponding to voltages externally applied (col. 5, lines 12-21). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to provide a piezo-electric medium

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layer on the first area, for the purpose of increasing the thickness of the first area so the heights of the first and second area are equal (see figure 9) to create diffraction patterns.

Regarding claim 5, Kowarz (figure 10) is interpreted as further disclosing a plurality of pairs of the first and the second areas are formed one after another in a cyclic manner.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jack Dinh whose telephone number is 571-272-2327. The examiner can normally be reached on M-F (9:30 AM - 6:00 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Y. Epps can be reached on 571-272-2328. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jack Dinh

upervisory Patent Examine Technology Center 2800

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